



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 09/982,855 Confirmation No. 7689
Applicant : Richard A. Metzler
Filed : 10/22/2001
TC/A.U. : 2813
Examiner : Yennhu B. Huynh
Title : Sidewalls As Semiconductor Etch Stop and
Diffusion Barrier

Docket No. : 5802P018X
Customer No. : 8791

Commissioner for Patents
PO Box 1450
Alexandria VA 22313-1450

AMENDMENT AND RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the Office action mailed on 12/15/2003,
please enter the following amendments and remarks in the above-
identified application as follows:

DRAWING amendments begin on page 2.

SPECIFICATION amendments begin on page 3.

CLAIM amendments begin on page 5.

REMARKS begin on page 18.

CONCLUSION and signature is on page 25.

APPENDIX I of 1 clean drawing sheet is attached hereto
following page 25.

APPENDIX II of 1 annotated drawing sheet of the amended
figures is attached hereto following Appendix I.